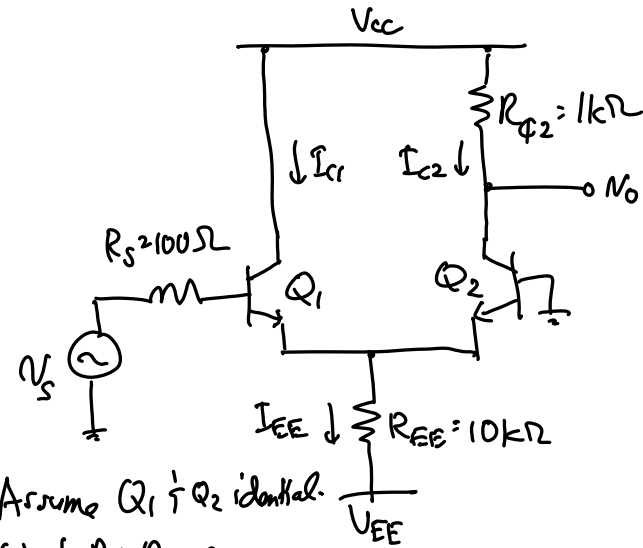


Lecture 5: MOS Inspection Analysis

- Announcements:
 - HW#1 will be due at 6 p.m. today
 - ↳ Change in time from 5 p.m. to 6 p.m. to accommodate people with classes that go till 5 p.m.
 - HW#2 is online and is due next Tuesday, at 6 p.m.
 - Lab#1 is online
 - ↳ Labs start next week → go to your lab section
 - As indicated in your syllabus, next Tuesday is a travel day for me, so I will miss lecture that day
 - ↳ Make-up lecture TBA - shooting for Friday afternoon
 - Lecture Topics:
 - ↳ Multi-Tx Amplifier Examples
 - ↳ MOS Inspection Analysis
-
- Last Time:
 - Multi-TX inspection analysis
 - Continue with this



Inspection Analysis of a Multi-Transistor Ckt.



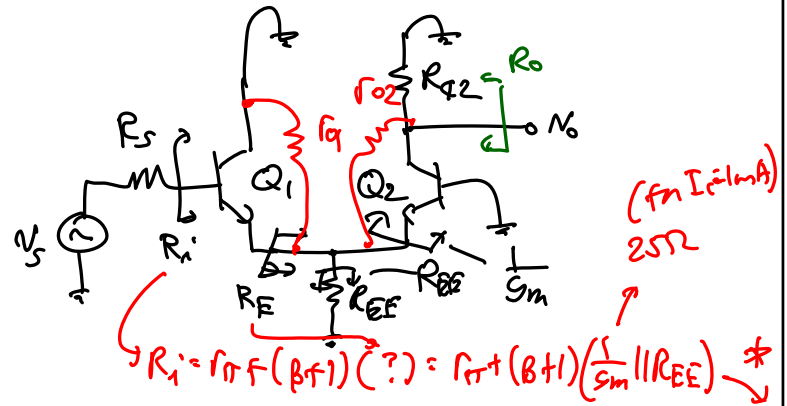
Assume Q_1 & Q_2 identical.
 Want R_i, R_o, g_{m1} .

$$I_{C1} = I_{C2} = \frac{I_{EE}}{2} \rightarrow r_{\pi 1} = r_{\pi 2} = r_{\pi}$$

$$r_{o1} = r_{o2} = r_o$$

$$g_{m1} = g_{m2} = g_m$$

S.S. Ckt. ↓



$R_i = r_{\pi} + (\beta+1) \left(\frac{1}{g_{m2}} \parallel r_{\pi 2} \parallel R_{E2} \parallel R_{E1} \right)$

 $R_i = r_{\pi} + (\beta+1) \frac{1}{g_m} \Rightarrow R_i = 2r_{\pi}$

 $R_o = r_{o2} \left(1 + \frac{g_{m2} (1/g_{m1})}{1 + (0 \parallel r_{\pi 2})} \right) \parallel R_{E2}$

 $R_{E2} \rightarrow$ usually large for good CMRR

$\frac{r_{\pi} + R_S}{\beta+1} = \frac{1}{g_{m1}} + \frac{R_S}{\beta+1}$

 $R_S = 500 \Omega$

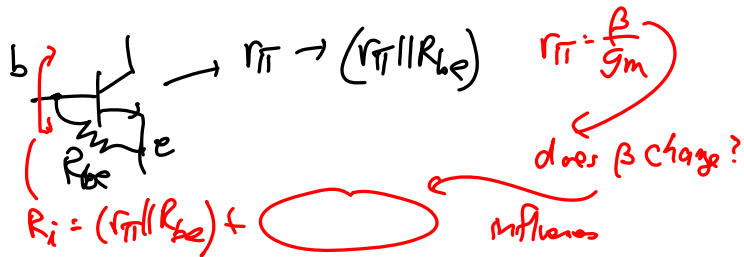
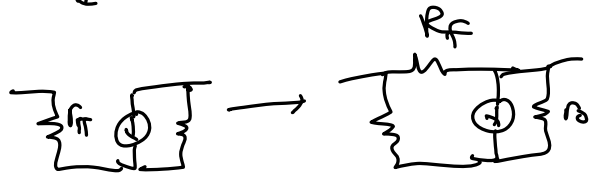
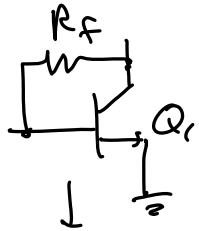
 $R_{E2} \approx (2r_{o2}) \parallel R_{E2} \approx R_{E2}$

$\frac{V_o}{V_s} = \frac{V_o}{V_s} \cdot \frac{V_{N1}}{V_{N1}} \cdot \frac{V_{N2}}{V_{N2}}$

 $\frac{V_o}{V_s} = \frac{2r_{\pi}}{R_S + 2r_{\pi}} \cdot \frac{1}{g_{m1}} \cdot \frac{1}{g_{m2}} \cdot g_{m2} R_{E2}$

 $\frac{V_o}{V_s} = \frac{2r_{\pi}}{R_S + 2r_{\pi}} \cdot \frac{1}{2} \cdot g_{m2} R_{E2}$

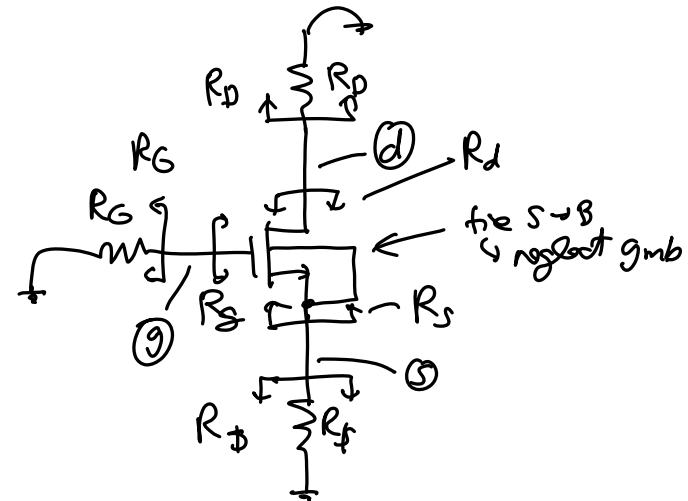
Inspection analysis might not work when you have feedback!



- Try to figure out whether or not there is a different beta and come up with an inspection formula for this case
- This will be discussed in discussion section, but try to come up with the solution on your own

Mos Kristin Ckt.

- ⇒ for now, ignore Body effect (i.e., ignore g_{mb})
- ⇒ use the same inspection formulas as bipolar, but use: $\beta \rightarrow \infty$, $r_{\pi} = \frac{\beta}{g_m} \rightarrow \infty$



⇒ refer to the "Inspection Formula Sheet" for bipolar:

$$R_b = \left(\frac{1}{g_m} + R_E \right) (B+1) \xrightarrow{\beta \rightarrow \infty} R_g = \infty$$

$$R_e = \frac{1}{g_m} + \frac{R_B}{B+1} \xrightarrow{\beta \rightarrow \infty} R_s = \frac{1}{g_m}$$

$$R_c = r_o \left[1 + \frac{g_m R_f}{1 + (R_B/r_{\pi})} \right] \xrightarrow{\beta \rightarrow \infty} R_d = r_o [1 + g_m R_f]$$

$$\frac{v_d}{v_g} = -G_m R_D, \quad G_m = \frac{g_m}{1 + g_m R_S}$$

$$\frac{v_d}{v_s} = -G_m R_D, \quad G_m = -g_m$$

$$\frac{v_s}{v_g} = \frac{g_m R_S}{1 + g_m R_S} = \frac{R_S}{g_m + R_S}$$

MOS Inspection Analysis

Ex. Common-Source Common-Drain Cascade

Want R_i, R_o, A_v .

↓ s.s. Ckt.

$R_i = \infty$
 $R_o = \frac{1}{g_{m2}} \parallel R_{D2} \approx \frac{1}{g_{m2}}$

$$\frac{v_o}{v_s} = A_v = \frac{v_d}{v_s} \cdot \frac{v_o}{v_d} \cdot \frac{v_o}{v_o}$$

$$\frac{v_o}{v_s} = (1)(-g_m R_{D1}) \left(\frac{R_{S2}}{R_{S2} + \frac{1}{g_{m2}}} \right)$$

Problem: Simulate in SPICE → the gain will be
 from 80-90% of what we calculate using
 the problem is that the g_{mb} was neglected when
 determining the source/follower gain
 one difference between
 bipolar & MOS hybrid- π
 models

Source Follower:
(w/ substrate grounded)

insert hybrid- π model

$v_{gs} = v_i - v_o$
 $v_{bs} = -v_o$

$$g_m(v_i - v_o) = v_o(g_{mb} + g_{ds} + G_s)$$

$$\Rightarrow A_{vs} = \frac{v_o}{v_i} = \frac{g_m}{g_m + g_{mb} + g_{ds} + G_s}$$

$$A_{vs} \approx \frac{g_m}{g_m + g_{mb}} = \frac{1}{1 + \eta}$$

$\eta = \frac{r_o}{2\sqrt{V_{SB} + 2\phi_f}}$

Body factor $\left\{ \begin{array}{l} R_s \rightarrow \infty \rightarrow G_s = 0 \\ g_{ds} \ll g_m + g_{mb} \end{array} \right.$

To make this = '1', do this:

← not always practical ...

Can get high density of Xsistor \uparrow
 ↓ to tie all sources to bulk:

min. spacing
 min. spacing
 density of Xsistor \ll
 → more \$!

- For cost reasons, bulks are rarely tied to sources in circuits like followers or differential pairs
- So you need to be able to deal with the g_{mb} 's when doing small-signal analysis
- See the MOS inspection formulas at the end of this lecture

Effect of g_{mb}

$R_s = \frac{1}{g_m + g_{mb} + g_{ds}}$
 $= \frac{1}{g_m} \parallel \frac{1}{g_{mb}} \parallel \frac{1}{g_{ds}}$

$R_s = \frac{1}{g_m + g_{mb}}$

So far \rightarrow focus on "midband":

Low Freq. Midband High Freq.

Mos Inspection Formulas w/ Substrate Grounded

Only difference from "substrate tied to source" case is that g_m is replaced by $g_m + g_{mb}$ in some of the formulas particularly ones where the source is involved!

$R_g = \infty$
 $R_s = \frac{1}{g_m + g_{mb}}$
 $R_d = r_o [1 + (g_m + g_{mb}) R_s]$
 $\frac{V_d}{V_g} = -G_m R_d$, $G_m = \frac{g_m}{1 + (g_m + g_{mb}) R_s}$
 $\frac{V_d}{V_s} = -G_m R_d$, $G_m = -(g_m + g_{mb})$
 $\frac{V_s}{V_g} = \frac{g_m R_s}{1 + (g_m + g_{mb}) R_s}$

Remark: When the substrate is tied to the source, $g_{mb} = 0$.